

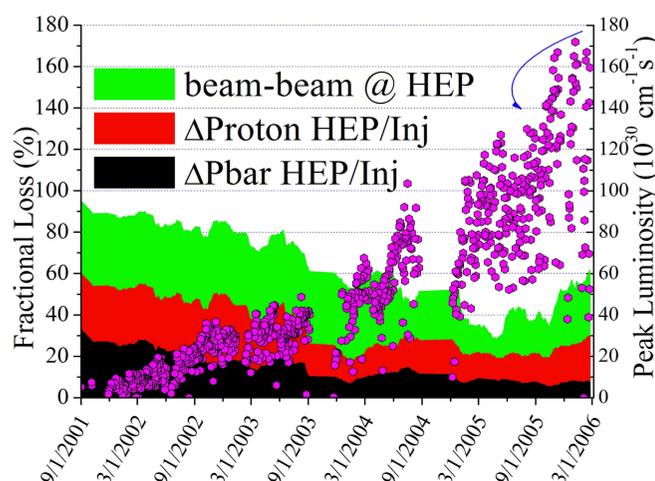
# The 2nd Tevatron Electron Lens and tests of a new electron gun in the framework of Beam-Beam Compensation project



Yu. Alexahin, V. Kamerdzhev, G. Kuznetsov, V. Scarpine, V. Shiltsev, X.L. Zhang, Fermilab

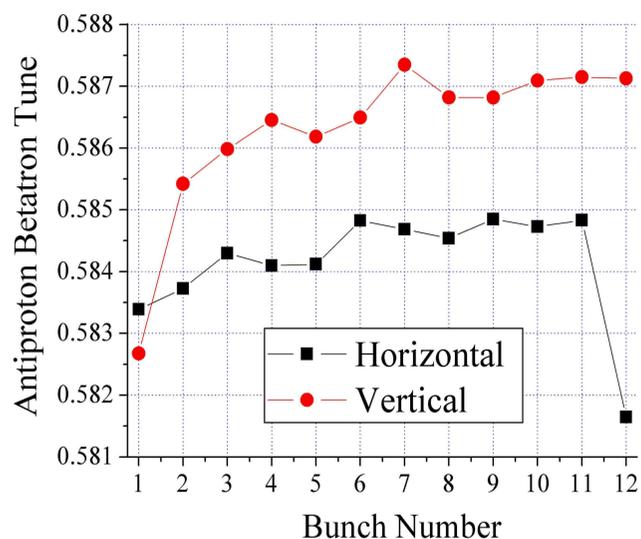
## Introduction

### Beam losses and peak luminosity in the Tevatron



Effects associated with both head on and parasitic beam-beam interaction have been observed in the Tevatron.

### Bunch-by-bunch tune spread as a result of parasitic beam-beam interaction

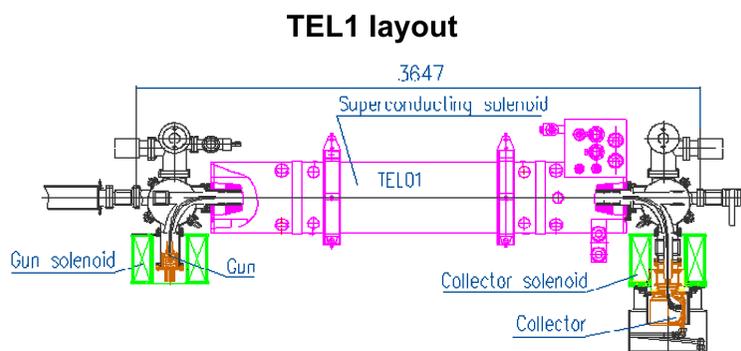


The goal of linear Beam-Beam Compensation (BBComp) is to reduce beam losses by reducing bunch-by-bunch tune spread. Bunches circulating in the machine have to be treated individually.

A device called Tevatron Electron Lens (TEL) has been designed and installed in 2001. Pulsed electron beam is placed on pbar/proton orbit. A number of beam studies showed tune shifts up to 0.009.

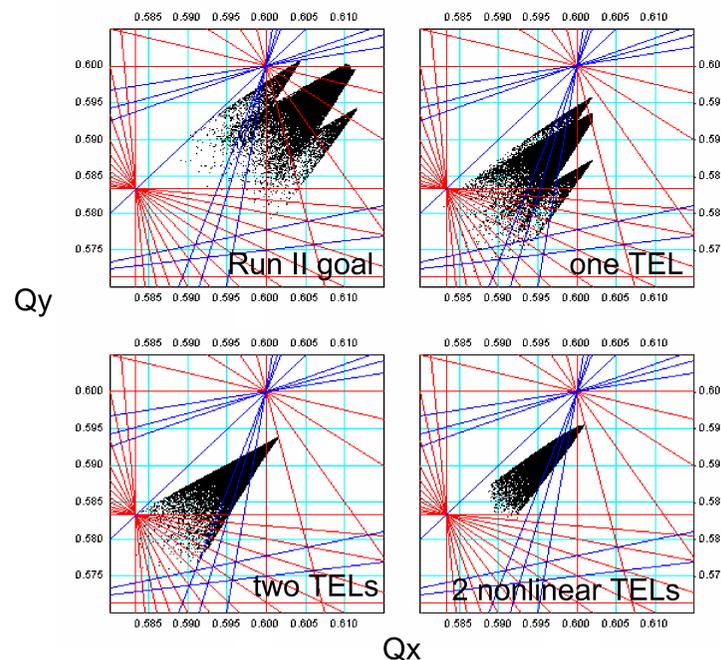
## Project status, results

TEL1 has been used successfully to perform BBComp studies and became an operational device for abort gap cleaning.



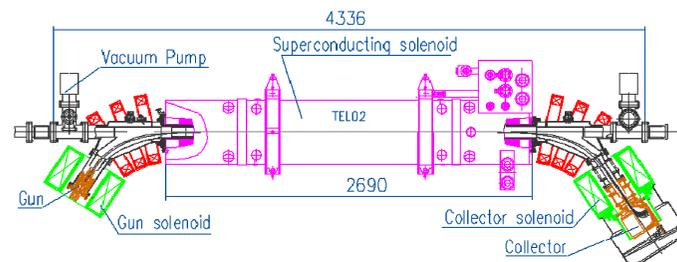
Calculations showed that a second TEL is needed in order to efficiently reduce tune spread in both planes

### Calculated pbar tune spread

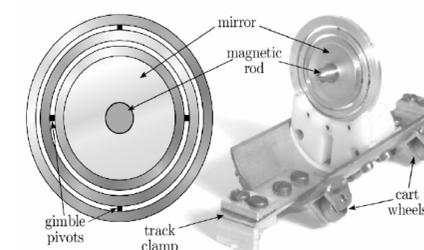


TEL1 and TEL2 layouts are different. TEL2 utilizes 57° bending angle instead of 90° in case of TEL1. Additional short solenoids has been added to increase magnetic field in both bends. This allows for much more flexibility in magnetic field settings.

### TEL2 layout

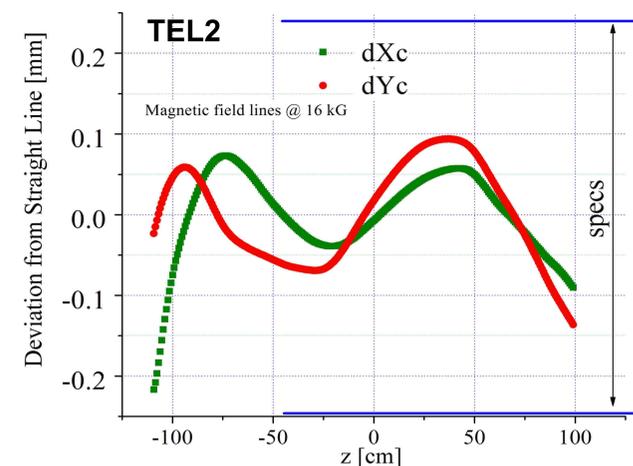


TEL2 has been tested prior to installation in the Tevatron. Magnetic field quality was measured using a hall probe and a laser based method. The second method utilizes a laser which is aligned along the solenoid axis. Its light is reflected by a magnetic mirror which is mounted on a cart dragged through the solenoid. The light is detected by means of a position sensitive detector. Since the mirror aligns itself perpendicular to magnetic field lines, the measured light spot position is a measure of magnetic line straightness. Measured straightness agrees with initial specification.



Mirror used to measure magnetic line straightness

### Straightness of magnetic lines in the main solenoid



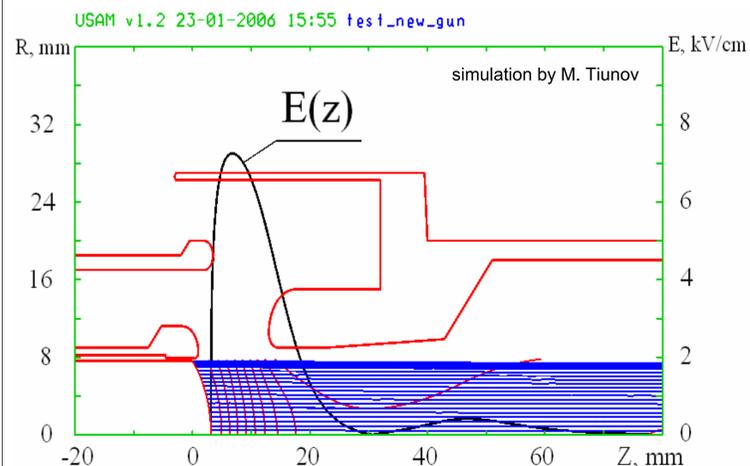
### TEL2 installed in the Tevatron



## Development of electron guns

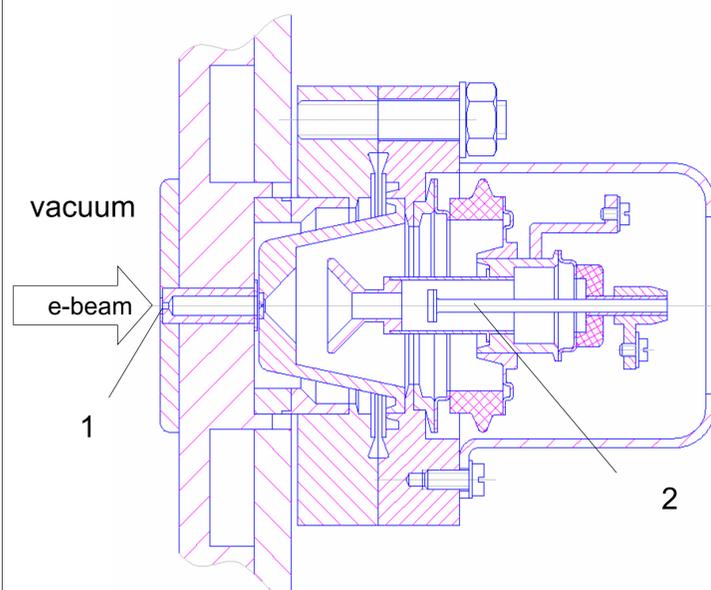
TEL1 was initially equipped with a high perveance gun that features uniform (flat) transverse charge distribution. Beam studies using this gun showed tune shifts up to 0.009 accompanied by high losses due to edge effects. A "gaussian" gun was introduced in 2002 and allowed to greatly reduce losses. To make e-beam alignment less critical and to increase the perveance a new smooth-edge-flat-top (SEFT) gun was commissioned in 2005 showing a good compromise between perveance and electron beam profile for linear BBComp.

### Geometry and simulation of SEFT gun



Gun performance has been studied on the test bench. The collector of the test facility is equipped with a beam analyzer that allows to measure transverse distribution of e-current density (profile).

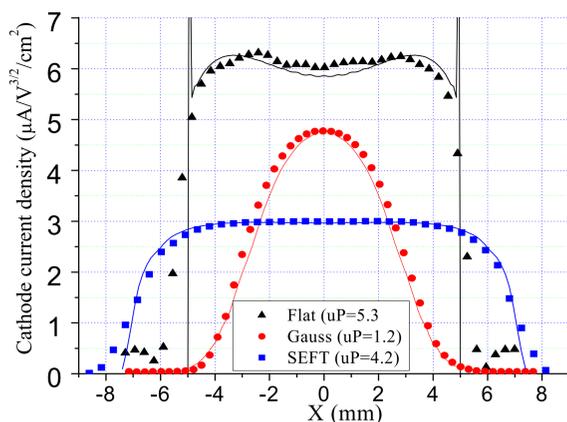
### Beam analyzer



1 - 0.2 mm hole, 2 – current probe

A small fraction of a magnetized electron beam (propagating from left to right) passes through a 0.2 mm hole and hits the probe. Moving electron beam by means of horizontal and vertical corrector coils and simultaneously recording the probe current makes it possible to measure electron beam profiles.

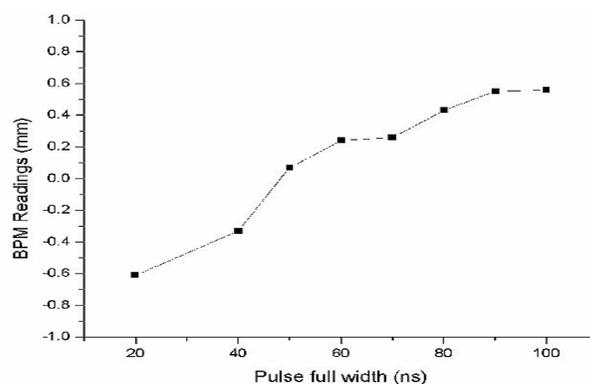
### e-beam profiles, measured and calculated



### Improvement of BPMs

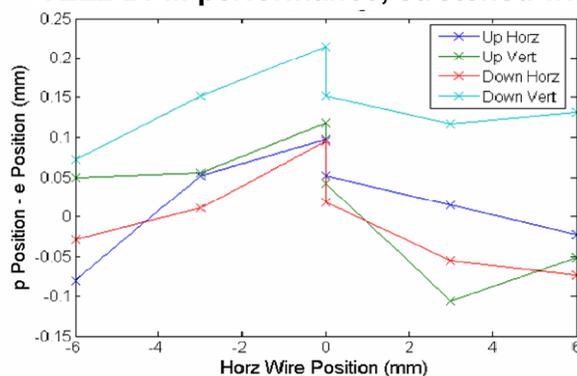
TEL1 BPMs (diagonally cut cylinders) are known to report different position depending on beam pulse width. The difference can be up to 1.2 mm.

#### TEL1: beam position vs pulse width



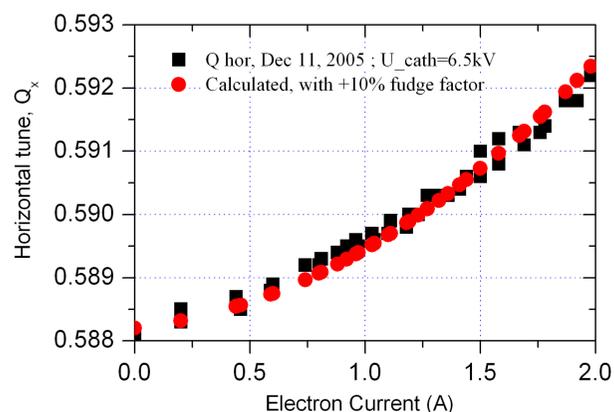
TEL2 BPM design utilizes four plate geometry with grounded electrodes between the plates to reduce crosstalk. They have been calibrated using a stretched wire and electron beam pulses of different width. The accuracy is better than 0.2 mm.

#### TEL2 BPM performance, stretched wire

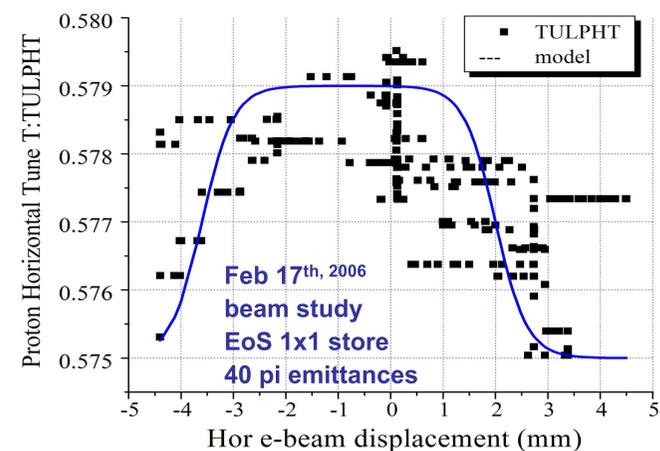


### Measured tune shift and lifetime (TEL1)

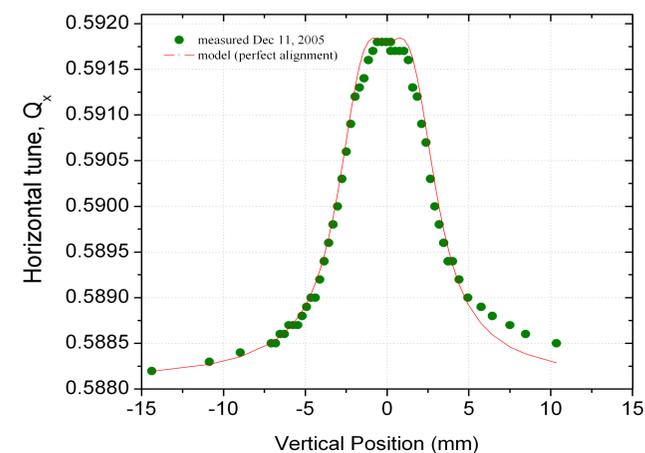
#### dQx vs e-current



### dQx vs horizontal e-beam displacement



### dQx vs vertical e-beam position



Using SEFT gun lifetimes of 700 hrs with dc e-beam and 340 hrs in pulsed regime have been observed. Presence of e-beam does not effect life time significantly. However, losses occur while tuning e-beam. Typically peak e-current was in the range 0.7-2 A.

## Summary and plans

- TEL2 has been tested and installed in the Tevatron together with a new solid state high voltage modulator, commissioning underway
- TEL2 beam diagnostics has been improved
  - tests of new BPMs confirmed better accuracy
  - "scraping" electrode added
- A SEFT electron gun has been built studied on a test bench and commissioned. Beam studies confirmed the expected performance.

- Assemble two more SEFT guns (in manufacturing)
- Find an alternative way to clean the abort gap
- Use both TELs for Beam-Beam compensation
- Compensate many/all bunches simultaneously at low peak e-currents
- Improve e-beam stability/ripple to reduce losses
- Perform simulations of:
  - Lifetime vs e-beam alignment
  - How does the bend shape effect BBComp
  - Lifetime vs dispersion